

Recent results of NIO1 negative ion source and future improvements

P. Veltri^{1,2}, M. Cavenago², G. Serianni¹, V. Antoni¹, C. Baltador¹, P. Barbato¹, M. Barbisan¹, L. Baseggio¹, M. Bigi¹, M. Brombin¹, V. Cervaro¹, M. De Muri¹, F. Degli Agostini¹, D. Fasolo¹, L. Franchin¹, N. Fonnesu¹, T. Kulevoy^{2,3}, B. Laterza¹, M. Maniero¹, L. Migliorato¹, A. Minarello², R. Pasqualotto¹, T. Patton¹, S. Petrenko^{2,3}, A. Pimazzoni¹, D. Ravarotto¹, M. Recchia¹, R. Rizzieri¹, L. Romanato¹, F. Rossetto¹, E. Sartori¹, M. Sattin², P. Sonato¹, C. Taliercio¹, L. Trevisan¹, B. Zaniol¹ L. Zanotto¹, D. Zella¹, S. Zucchetti¹.

¹ Consorzio RFX, CNR, ENEA, INFN, Università di Padova, Acciaierie Venete SpA -Padova - Italy ²INFN-LNL, v.le dell'Università 2, I-35020, Legnaro (PD) Italy ³ ITEP, B. Cheremushkinskaya 25, 117218, Moscow, Russia

NIO1 Characteristics and Scopes





Overview



• The core of experimental set-up can be divided in 3 functional parts:



Overview



- Flexible modular design
- Source is a tower of disk assemblies connected by O-rings
- Accelerator includes separate modules held together by compression bars for mechanical and electrical rigidity (PEEK)
- HV Insulation by 3 alumina ring
- Modules sealed with elastomer O-rings







The source: Plasma Chamber



- Source itself is very modular:5 parts sealed by elastomer O-rings
- Copper gasket on CF16 Flanges (diagnostic ports and Cs oven)
- Plasma is generated in a cylinder, R=5cm,L=20 cm
- Negative charges extracted by 3x3 apertures in the source front



• Source walls: copper alloy with molybdenum plating (sputtering!)

The coil assembly

- 7 Turns copper wire, water cooled.
- Polysulfone shells to keep turns in place
- Alumina to insulate from the plasma



- Caesium injection controlled by oven temperaure.
- Thermally isolated copper pipe (overheated >470 K)

The Source: Extractor



- H- are extracted from 9 apertures (Ø7.6 mm) arranged in a 3x3 pattern
- Plasma grid (PG) realized in electrodeposited copper + stainless steel (downstream)



- Cs injection in the proximity of PG
- PG and Bias circuit: dry air for heating to 400 K (Cs optimal coverage: 1/2 monolayer)





Status of the Experiment: 2015 campaigns

Gas: Air

CONSORZIO RFX Ricerca Formazione Innovazione

Gas: H₂

First experiment in H2 and Air focused on plasma ignition and scaling with RF power and pressure

450 ⊨p=9e-4 3.5 400 **-**p=4e-4 Line intensity (a.u.) 350 3 Line Intensity (a.u) H mode 300 2.5 250 2 200 1.5 150 1 E mode 394 100 £ 0.5 ž 50 0 0 400 600 800 1000 1200 1400 1600 1800 750 250 350 550 650 850 450 **RF Power (W) RF Power (W)**

- Air: transition from capacitive to inductive coupling at around 400 W
- Hydrogen transition occurs at higher power (P>1400 W)

Towards 2016 campaigns



Experiment at high RF power (<1.7 kW) caused a damage on the allumina insulator (elastic bolt unbalanced loosening?).

During the shutdown many improvements were made to the set up:

- Integration of PS completed (fast interlock, protection system,..)
- New insulator of Pyrex were procured and installed









Allumina insulator source walls and PG after source opening



Pyrex Insulator

Mo cover

Towards 2016 campaigns: New diagnostics



• Beam profile and calorimetry by CFC tile







- Beam Emission Spettroscopy (BES): 3 lines of sight installed on a lateral port,
- New spectrometer procured



BEAM



G. Serianni et al. AIP Conf. Proc. 1655, (2015)

Towards 2016 campaigns: New diagnostics



- CFC biasing and current measurment:
- Grounded Grid (also called PA) current measurment



• Electric measure on CFC has a strong synergy with calorimetric estimation.





- Secondary electrons
 - on GG: automatically recollected
 - on CFC tile: a biasing is required



2016 campaigns: O⁻ beams

- RF power was limited to < 800 W (Pyrex insulator)
- Beam extraction experiments in Air and O₂ (H2 plasma too weak)
- Use of O- has many advantages:
 - Relative abundance of O-
 - High beam density
 - Less deflected by EG magnets



- Large electron currents are extracted
- EG magnets assure no electron leakage in the high voltage region:
- $I_{GG} + I_{CFC}$ assumed as the beam current.
- Beam current gradually increased up to >1 mA.

Pressure scan in Air



• From literature [Stoeffels, phys rev E, Tanaka ..]: In O₂ plasma we can expect a negative ions to electrons ratio ranging from 0.2 up to 10, depending on pressure, RF power and e- temperature.



- Also in NIO1 Beam current strongly depend on gas pressure
- Electron current decreased with gas pressure
- Pressure is limited by accelerator breakdown; subject under investigation.

P=600 W Vext=0.8 kV Vacc=8 kV

O₂ Plasma







O₂ Plasma characterization in progress

Using pure oxygen gives a factor of 3 in beam current under the same conditions

Less than the naïve expectation of 5 (stoichiometric ratio)

Bias Voltage Scan



Many part can be biased independently thanks to macor insulators. In the actual set-up the PG assembly was biased with respect to the source walls.





- Strong reduction of coextracted electrons
- Increase of beam current

Filter Field Scan



A tranversal Magnetic field is used to filter out the high energy electrons form the extraction region.

Filter field generated by 0.4 kA current flowing into the PG and its return pipes



Electron current is decreased and beam current increases: destruction of O⁻ is reduced in the proximity of PG





Beam Optics



Constant ratio VGG/VEG=10

At firt order focal length is hence kept constant: thin lens approximation

 $f = (E_2 - E_1)/4V$



0.8 0.5 Air, p=2.5e-4, IPG=200A, Bias=20V, 600 W Air, p=2.5e-4, IPG=200A, Bias=20V, 600 W • Air, p=2.5e-4, IPG=200A, Bias=20V, 700 W • Air, p=2.5e-4, IPG=200A, Bias=20V, 700 W 0.7 ▲ Air, p=2.5e-4, IPG=400A, Bias=20V, P=700 W ▲ Air, p=2.5e-4, IPG=400A, Bias=20V, P=700 W 0.45 0.6 **Beam current** 0.5 0.4 0.3 Current Increases PA/CFC current 0.4 0.35 0.2 0.3 0.1 0 0.25 0.2 0.4 0.8 1.2 0 0.5 1 1.5 0 0.6 1 1.4 EG Voltage (kV) EG Voltage (kV)

Beam divergence proportional to the ratio of PA/CFC current

When beam current is increased the optimal voltage is increased accordingly

Comparison with beam simulation





Assuming all EGcurrent is carried by electrons and all CFC+PA current is carried by O-:

$$I_{e} = 300 \text{ mA} \qquad Hence \qquad J_{e} \approx 750 \text{ A/m}^{2}$$

$$I_{O_{-}} = 1 \text{ mA} \qquad Hence \qquad J_{O_{-}} \approx 2.5 \text{ A/m}_{2}$$
Since
$$mO_{-/me} \approx 33000$$

$$vO_{-/ve} \approx 182$$
Both specie contributes to space
charge in the PG-EG gap

Current scaling with EG voltage was taken from real measurement

100000

Comparison with beam simulation: Fixed Vacc



No electron leackage in the high energy region. Limited beam interception on PA



Status of the Experiment: Future improvements







- With the new concept more then a tenfold increase in B·dl is possible
- Careful check of B penetration in the driver region



Status of the Experiment: Future improvements



- New EG: Ready to be installed
- Cs oven: deposition test
- Commissioning and/or installation of new components and diagnostics
 - FES
 - Electrostatic Probes
 - Tomography
 - Cavity ring Down







P. Veltri IPAB-2016, 14-16 March, Legnaro, Padova



